PATENT ABSTRACTS OF JAPAN

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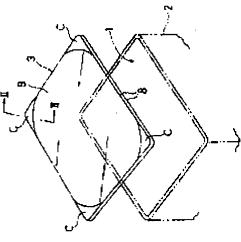
G03B 27/62 G03G 15/04	(71)Applicant: FUJI XEROX CO LTD	4 (72)Inventor: MIYAMOTO JUNZO
	oer : 59-146922	17.07.1984
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(54) EXPOSURE DEVICE OF COPYING MACHINE

(57)Abstract:

photosensitive surface uniform by peeling properly parts of a coating layer corresponding to respective corner parts of a platen to increase the light going from corner parts of the PURPOSE: To keep always the illuminance distribution of a projected image on a platen toward the photosensitive surface.

3 are peeled. Thus, the quantity of light irradiated from corner parts C of the platen 3 to the reduction of the transmittance due to the coating layer, the quantity of light irradiated to the smaller than the quantity of light irradiated to these parts. As the result, the quantity of light coating layer, and parts of this coating layer corresponding to corner parts C of the platen photosensitive surface is hardly smaller than that irradiated to corner parts C. Since the CONSTITUTION: Both faces of a platen 3 are coated with reflection preventing films 8, and the front face is coated with a transparent conductive film 9 furthermore to form a photosensitive surface from parts other than corner parts C of the platen 3 is slightly quantity of light reaching parts other than corner parts C is reduced uniformly by the



lack of illuminance on parts of the photosensitive surface corresponding to corner parts C is eliminated, and the copy quality is irradiated from corner parts C of the platen 3 and that from other parts are approximately equal to each other relatively, and a kept well.

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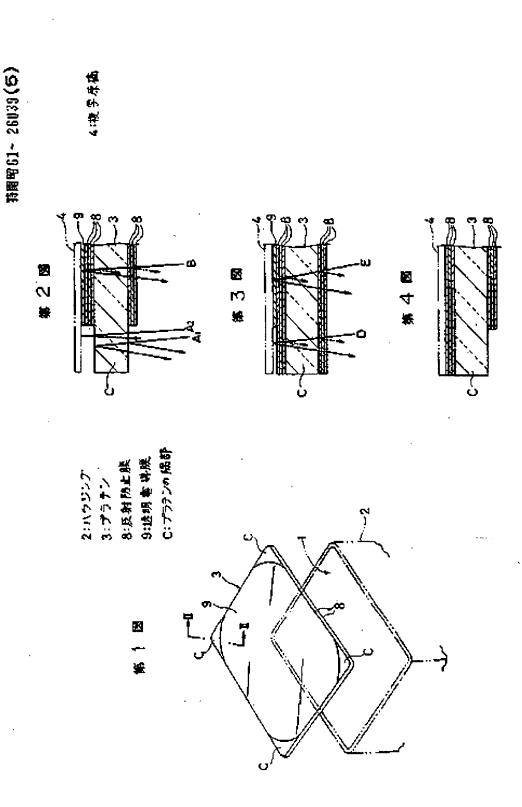
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